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Hugoniot Measurements of High Pressure Phase Stability of TitaniumSilicon Carbide (Ti3SiC2)
Shear instability of nanocrystalline silicon carbide during nanometric cutting

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The shear instability of the nanocrystalline 3C-SiC during nanometric cutting at a cutting speed of 100 m/s has been investigated using molecular dynamics simulation. The deviatoric stress in the cutting zone was found to cause sp3–sp2 disorder resulting in the local formation of SiC-graphene and Herzfeld-Mott transitions of 3C-SiC at much lower transition pressures than that required under pure compression. Besides explaining the ductility of SiC at 1500 K, this is a promising phenomenon in general nanoscale engineering of SiC. It shows that modifying the tetrahedral bonding of 3C-SiC, which would otherwise require sophisticated pressure cells, can be achieved more easily by introducing non-hydrostatic stress conditions. © 2012 American Institute of Physics.

It has been widely recognized that it is the high pressure phase transition (HPPT), now known as the Herzfeld-Mott transition1 that causes metallization of group-IV elements such as silicon and germanium which are brittle at room temperature.2 Such transformations are classed as metallic because they cause closure of the valence-conduction band gap due to overlap of wave functions and hence delocalization of the valence electrons.3

A similar phenomenon in 3C-SiC, specifically its occurrence during nanometric cutting, has yet to be investigated considering the importance of SiC as a potential candidate in large-scale quantum computing applications and high power electronic devices.4 Earlier studies have speculated on the transformation of 3C-SiC from its original diamond cubic lattice structure to a rocksalt structure during nano-indentation and pure compression.5,6 However, pure compression differs from hydrostatic pressure7 as it may have a component of deviatoric stress which can cause shear induced metallization via changes in bond angle.8 Also, the line contact between the cutting tip of the tool and the workpiece during nanometric cutting differs from the point contact during nano-indentation9 so nanometric cutting conditions result in an increased energy transfer compared with nano-indentation process. If the propensity to a Herzfeld-Mott transition is a function of the nano-indentation hardness of a material,1 the question arises as to whether or not 3C-SiC will show a rocksalt transformation or any other metallic phase during nanometric cutting. Hence, shear instability of nanocrystalline 3C-SiC during nanometric cutting became a motivational concern in the current work.

Nanometric cutting of a material using a single point diamond cutting tool is a typical practical example justifying the study of the effect of both hydrostatic and deviatoric components of stress coupled with the effect of elevated temperature. If, as suspected, the key to such processes lies in understanding the atomic level events, molecular dynamics (MD) should be an appropriate simulation approach. The relatively slow computational speed of MD can be overcome by using the multiscale simulation method which was first proposed in the year 1991.10 Subsequently various such coupling algorithms have been proposed, a review of which has been presented by Miller and Tadmor.11 Besides, some other coupling algorithms are also well known.12–18 One such investigation has been recently reported by the current authors19 involving multiscalar simulation using the quasi-continuum (QC) method. However, QC is still undergoing development to simulate complex diamond cubic lattices such as 3C-SiC. Considering the above limitations, this paper adopts a state-of-the-art, MD simulation employing a three-body potential energy function for describing the nanometric cutting of β-SiC (3C-SiC).

The simulation was performed using LAMMPS20 employing a Tersoff potential energy function.21,22 Tersoff potential energy function being three-body potential function is much better choice for covalent bond interactions of silicon and carbon in comparison to a pair potential like Morse. As a benchmark, the simulation results obtained for 3C-SiC were compared with silicon which is comparatively well studied. Both SiC and silicon were cut on the (010) surface using the cubic orientation of the diamond tool, thus maintaining the same boundary conditions. The total included angle of the diamond tool was chosen as 105° with a negative rake angle of −25° as this geometry helps to achieve better ductile response from brittle materials during nanometric cutting.23–25 A comprehensive methodology describing the MD simulation algorithm adopted in this work has been described elsewhere.26

Figure 1 shows a snapshot from the MD simulation during nanometric cutting of 3C-SiC where the yellow coloured atoms represent the diamond tool, green represents silicon atoms and red represents carbon atoms from the workpiece. Figure 1 shows the chips to curl as they detach from the bulk substrate in front of the cutting tool which suggests that 3C-SiC is similar to 6H-SiC27 in responding to the cutting forces in a ductile manner. Figure 1 also shows the region right underneath the cutting tool which experiences the highest stresses during the cutting operation. The stress representation in 3D and 2D is also shown schematically in Figure 1. The stress tensor for atom i during the simulation can be calculated using the following equation:

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broadened somewhat with angles for silicon appearing in the range of $80^\circ$ to $140^\circ$. This wide range in bond angle is consistent with polymorphic phase transformation of silicon during nanometric cutting. By contrast, the bond angle in 3C-SiC exhibited only two values (other than $109.5^\circ$) which are $105^\circ$ and $120^\circ$. This limited number of bond angles in 3C-SiC is an indication that it has not become polymorphic during nanometric cutting, unlike silicon. Additional confirmation of morphological change can be seen in the changes in C-C-C bond angle and in dihedral angle (Si-Si-C-C) brought about by the nanometric cutting. There is a distinct shift in C-C-C bond angle and Si-Si-C-C dihedral angle towards a value of $120^\circ$ from the original value of $109.5^\circ$.

This change in bond angle distribution ($109.5^\circ \rightarrow 120^\circ$) suggests a transformation from $sp^3$ to $sp^2$ bonding in the 3C-SiC during its nanometric cutting, which could be brought about by the intense shear stresses. The structure formed during this transition can be understood by the analysis of the radial distribution function (probability of finding an atom in a shell $dr$ at a distance $r$ from another atom chosen as a reference point), $g(r)$—shown in Figure 3.

As can be seen, there is an increase in $g(r)$ for SiC bond occurred at two interatomic distances, 1.75 Å, which is the reported length of Si–C double bonds and 2.05 Å. Given the analysis of $g(r)$, bond angle and dihedral angle, suggests that the transition of $sp^3$-SiC to $sp^2$-SiC can schematically be represented as shown in top portion of Figure 4 and compared with the structure of SiC nanotube shown at bottom.

Carbon atoms are smaller than silicon atoms and are more electronegative which causes the transformed structure to be chemically ordered even during its reconstruction. The geometry obtained in Figure 4 is difficult to realize through experiments, however, the relevant inter-layer spacings have been obtained experimentally as 0.38 nm.

This inter-layer spacing is attributed to a $\pi$-like bond and can be obtained by applying simple trigonometry to the proposed lattice structure as follows:

$$x = 2.05 \times \frac{\sin 30^\circ}{\sin 90^\circ} = 1.025 \text{ Å}$$

=>$Total$ $inter$-$layer$ $spacing$ $= 1.75 \text{ Å} + 2x = 3.8 \text{ Å}.$

An interesting observation relevant to this phenomenon is the mechanism of cleavage on either (111) or (011) planes which is the natural shear plane during nanometric cutting. It is likely that it would have resulted in inter-plane polarization, the two surfaces having atomic charges at the extremes.
between silicon and carbon. The resulting structure will stabilize via charge transfer between the opposite diameters of silicon and carbon (~0.27 eV) or a phase transition from the wurtzite to the graphite structure. It is further interesting to note that molecular stability calculations have predicted the existence of a SiC graphene tube with a \( sp^2 \) structure as shown in bottom part of Figure 4.

As illustrated in the bottom panel of Figure 4, the structure is not entirely planar but is rippled with Si atoms in a single plane and C atoms in alternate rows, above and below the Si atoms. A chiral vector defined by a pair of integers \((n,m)\) appearing in a translation vector \(c = na + mb\), where \(a\) and \(b\) are the two vectors defining the primitive cell of graphene, can be used to represent such structures. The effect of this chiral vector is that the structure will be conductive, i.e., metallic, as long as \(n-m\) is a multiple of 3. It has also been suggested that the chemically ordered SiC nanotubes of “armchair” \((6,6)\) type are slightly (by 0.05 eV/SiC atomic pair) more stable than \((12,0)\) SiC nanotubes and both are conductive as \(n-m\) is multiple of 3. Further, the fact that the band gap has vanished in this form of \( sp^2 \)-SiC satisfies the Herzfeld-Mott transition criterion. Hence, the \( sp^3 - sp^2 \) transition in 3C-SiC is consistent with a ductile or metallic response of SiC during nanometric cutting.

Due to the unavailability of larger size single crystal 3C-SiC wafer, although an experimental trial of nanometric cutting of 3C-SiC is not possible at this stage but MD simulation suggests that the deviatoric stress during nanometric cutting brings about \( sp^3 - sp^2 \) transition in 3C-SiC. The MD simulation further indicated the geometry of the \( sp^3 \) form of SiC through the analysis of radial distribution function angular distribution function and dihedral angles. Crucially, the nature of the bonding in nanocrystalline 3C-SiC can be altered by introducing non-hydrostatic stress conditions, previously thought to require much higher hydrostatic pressures.